## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s):	Thomas N. Horsky	) <u>CERTIFICATE OF MAILING BY</u> "EXPRESS MAIL"
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Title:	Electron Impact Ion Source	I hereby certify that this paper or fee is being deposited with the United States Postal Service  "Express Mail Post Office to Addressee" Service
Group Art Unit:	N/A	under 37 CFR §1.10 on the date indicated above and is addressed to the Mail Stop Patent  Application, Commissioner of Patent and Trademarks, P.O. Box 1450, Alexandria,
Examiner:	N/A	VA 22313-1450, on this date.    Maria   Irreola - Flores     (Typed or printed name of person mailing)     Signature of person mailing)     Signature of person mailing)
		)

MAIL STOP PATENT APPLICATION Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## **Information Disclosure Statement**

Dear Sir:

Pursuant to the provisions of 37 C.F.R. §§ 1.56, 1.97 and 1.98, Applicant submits a Form PTO-1449 and documents other than U.S. patents and published U.S. patent applications listed on Form PTO-1449. These documents identified on Form PTO-1449 are for consideration during the prosecution of the subject application. This document is being filed in accordance with 37 C.F.R. §§ 1.97(b) and before the first Official Action.

The Commissioner is hereby authorized to charge any additional fees which may be required with respect to this communication or credit any overpayment to Deposit Account No. 50-1214.

Should no proper payment for this communication be enclosed, as by a check being in the wrong amount, unsigned, postdated, otherwise improper or informal, or even entirely missing, the Commissioner is authorized to charge the unpaid amount to Deposit Account No. 50-1214. This communication is filed in triplicate.

The above constitutes information that an Examiner may find material to the examination of the subject application; however, it does not negate the patentability of the subject invention. Furthermore, it is not intended that submission of this information be taken as a representation that a search has been made or that no information which is more material exists.

Respectfully submitted,

Katten Muchin Zavis Rosenman

Bv:

John S. Paniaguas

Reg. No. 31,051

Date: 12-30-03

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Form PTO-1449									Docket Number 211843-00022	Application Number 10/183,768				
INFORMATI N DISCLOSURE CITATI N IN AN APPLICATI N									Applicant Thomas Horsky					
(Use several sheets if necessary)									Filing Date June 26, 2002	Group Art Unit 2881				
								U. S. PAT	ENT DOCUMENTS					
EXAMINER INITIAL	DOCUMENT NUMBER							DATE	NAME	CLASS	SUB CLASS	FILING I		
	6	4	5	2	3	3	8	9/17/02	Horsky					
	6	2	8	8	4	0	3	9/11/01	Horsky et al.					
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	DOCUMENT NUMBER DATE							DATE	COUNTRY	CLASS	SUB CLASS	Yes	No	
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EXAMINER				<u> </u>						DATE CONSI	nepen			
EXAMINER: Initial if c	itation c	onsidere	d, wheth	er or not	citation	is in conf	ormance	with MPEP § 609; Draw	r line through citation if not in conformance and not consider			next commu	nication to	